

LMP2012QML-SP Neutron Displacement Damage Characterization



ABSTRACT

This report presents the effect of neutron displacement damage (NDD) on the LMP2012QML-SP device. The results show that all devices were fully functional and within production test limits after having been irradiated up to 1×10^{12} n/cm² (1-MeV equivalent). A sample size of fifteen units was exposed to radiation testing per (MIL-STD-883, Method 1017 for Neutron Irradiation) and an additional two unirradiated sample devices was used for correlation. All devices used in the experiment were from lot date code B9B1044A. Electrical testing was performed at Texas Instruments before and after neutron irradiation using the production test program for LMP2012QML-SP.

Table of Contents

1 Overview	2
2 Test Procedures	3
3 Facility	3
4 Results	3
A Appendix A: Test Results	4

List of Figures

Figure 1-1. LMP2012QML-SP Device.....	2
---------------------------------------	---

List of Tables

Table 1-1. Overview Information.....	2
Table 2-1. Neutron Irradiation Conditions.....	3

Trademarks

All trademarks are the property of their respective owners.

1 Overview

The LMP2012QML-SP device is a dual high precision, rail-to-rail output operational amplifier with excellent CMRR and PSRR ratings, and does not exhibit the familiar 1/f voltage and current noise increases that plague traditional amplifiers. The QMLV version of the LMP2012 has been rated to tolerate a total dose level of 50-krad(Si) radiation by Ionizing radiation (Total Dose) test method 1019.4 of MIL-STD-883.

General device information and testing conditions are listed in [Table 1-1](#).

Table 1-1. Overview Information

TI Part Number	LMP2012QML-SP
Device Function	Rail-to-Rail Output Operational Amplifier
Technology	CS080ABI
A/T Lot Number / Date Code	B9B1044A
Unbiased Quantity Tested	15
Exposure Facility	Lowell
Neutron Fluence (1-MeV equivalent)	1.0×10^{11} , 3.2×10^{11} , 1.0×10^{12} n/cm ²
Irradiation Temperature	25°C

TI may provide technical, applications or design advice, quality characterization, and reliability data or service providing these items shall not expand or otherwise affect TI's warranties as set forth in the Texas Instruments Incorporated Standard Terms and Conditions of Sale for Semiconductor Products and no obligation or liability shall arise from Semiconductor Products and no obligation or liability shall arise from TI's provision of such items.

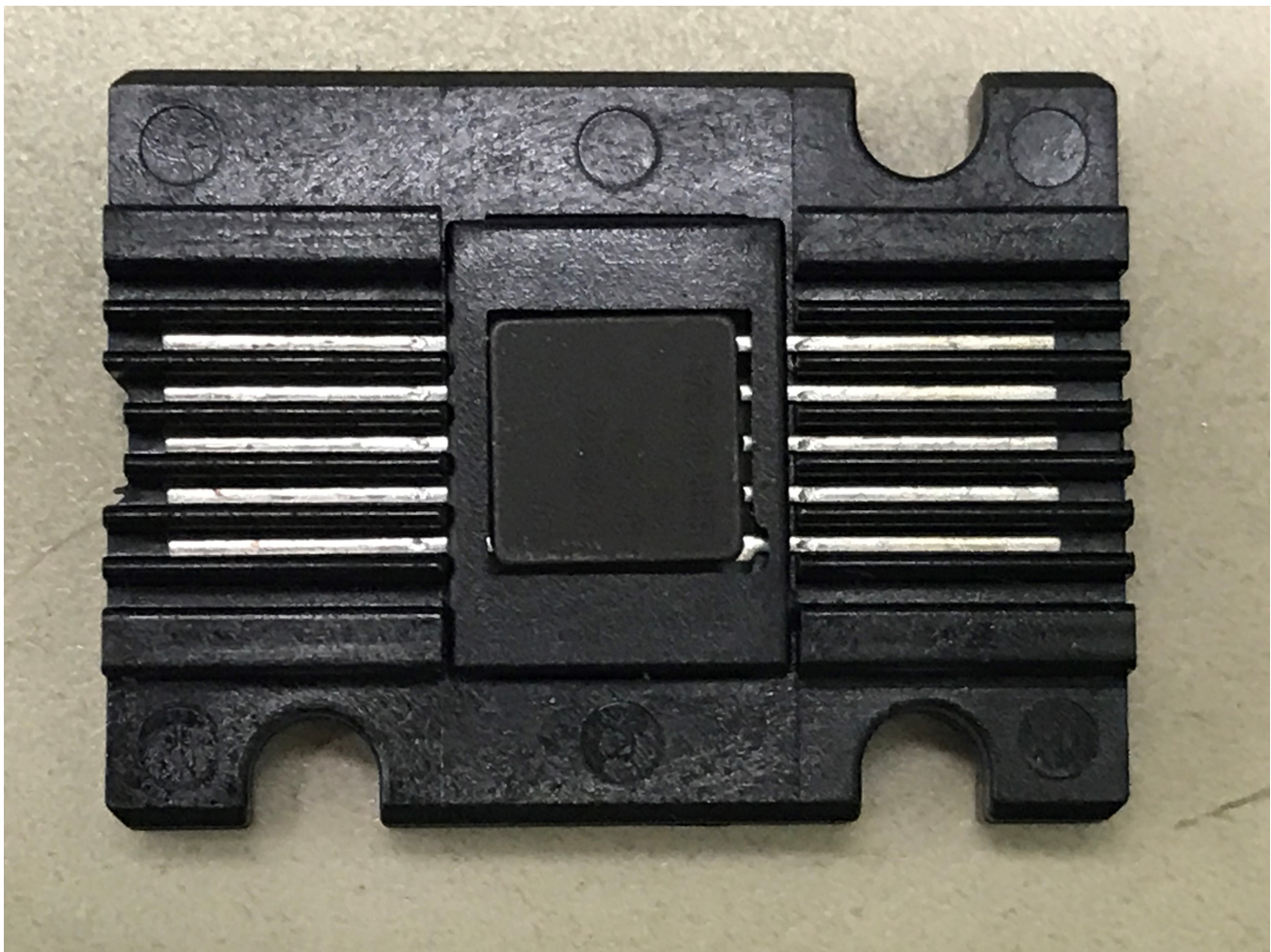


Figure 1-1. LMP2012QML-SP Device

2 Test Procedures

The LMP2012QMLV-SP was electrically pre-tested using the production automated test equipment program.

General test procedures were IAW MIL-STD-883, Method 1017 for Neutron Irradiation of LMP2012QMLV-SP.

Table 2-1. Neutron Irradiation Conditions

Group	Sample Qty	Neutron Fluence (n/cm ²)	Bias
A	5	1.0×10^{11}	Unbiased
B	5	3.2×10^{11}	Unbiased
C	5	1.0×10^{12}	Unbiased

3 Facility

Devices were exposed via fast neutron irradiation (FNI) at the University of Massachusetts Lowell Research Reactor (UMLRR). The facility is designed to give a fast flux level $\geq 10^{11}$ n/cm²-s, with relatively low thermal fluence and gamma dose rates. Samples with a cross-sectional area as large as 30 cm (12 in) × 30 cm (12 in) and up to 15-cm (6-in) thick can be irradiated. The fast neutron flux is designed to be nearly uniform over the 30-cm (12-in) × 30-cm (12-in) area facing the core, and the fast fluence variation through the sample thickness is minimized via a single 180° rotation of the sample canister at the midpoint of the irradiation period. The FNI facility offers a significantly larger sample volume than previously available within the University of Massachusetts Lowell Research Reactor (UMLRR).

The fluences are calculated based on 1-MeV equivalences.

Detailed information of the radiation facility is available at the following link:

www.uml.edu/docs/FNI%20Brochure_tcm18-90375.pdf

4 Results

There were no functional failures at any irradiation level. All parametric measurements remained well within all *LMP2012QML Dual High Precision, Rail-to-Rail Output Operational Amplifier data sheet* limits for all exposure levels. All parametric measurements remained well within the production test limits which are guard-banded from the data sheet limits. The full parameter list and graphs are found in [Appendix A](#).

A Appendix A: Test Results

This appendix contains the detailed test results.

IMPORTANT NOTICE AND DISCLAIMER

TI PROVIDES TECHNICAL AND RELIABILITY DATA (INCLUDING DATA SHEETS), DESIGN RESOURCES (INCLUDING REFERENCE DESIGNS), APPLICATION OR OTHER DESIGN ADVICE, WEB TOOLS, SAFETY INFORMATION, AND OTHER RESOURCES "AS IS" AND WITH ALL FAULTS, AND DISCLAIMS ALL WARRANTIES, EXPRESS AND IMPLIED, INCLUDING WITHOUT LIMITATION ANY IMPLIED WARRANTIES OF MERCHANTABILITY, FITNESS FOR A PARTICULAR PURPOSE OR NON-INFRINGEMENT OF THIRD PARTY INTELLECTUAL PROPERTY RIGHTS.

These resources are intended for skilled developers designing with TI products. You are solely responsible for (1) selecting the appropriate TI products for your application, (2) designing, validating and testing your application, and (3) ensuring your application meets applicable standards, and any other safety, security, regulatory or other requirements.

These resources are subject to change without notice. TI grants you permission to use these resources only for development of an application that uses the TI products described in the resource. Other reproduction and display of these resources is prohibited. No license is granted to any other TI intellectual property right or to any third party intellectual property right. TI disclaims responsibility for, and you will fully indemnify TI and its representatives against, any claims, damages, costs, losses, and liabilities arising out of your use of these resources.

TI's products are provided subject to [TI's Terms of Sale](#) or other applicable terms available either on ti.com or provided in conjunction with such TI products. TI's provision of these resources does not expand or otherwise alter TI's applicable warranties or warranty disclaimers for TI products.

TI objects to and rejects any additional or different terms you may have proposed.

Mailing Address: Texas Instruments, Post Office Box 655303, Dallas, Texas 75265
Copyright © 2022, Texas Instruments Incorporated